

Effect of purity of Ti on growth behaviour of Ti suicide formed in bulk Ti/Si diffusion couple

Shimozaki T, Chikumaru K, Wakamatsu Y, Onishi M.

Nippon Kinzoku Gakkaishi/Journal of the Japan Institute of Metals

1996; 60(1):29-36

ARTICLE IDENTIFIERS

DOI: 10.2320/jinstmet1952.60.1_29

PMID: unavailable

PMCID: not available

JOURNAL IDENTIFIERS

LCCN: not available

pISSN: 0021-4876

eISSN: not available

OCLC ID: not available

CONS ID: not available

US National Library of Medicine ID: not available

This article was identified from a query of the SafetyLit database.